

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Attorney Docket No. 253/006

In re Application of

Jung-Ho LEE, et al.

Serial No.: 09 686,624

Filed: October 12, 2000

Group Art Unit: 2823

For: SPIN-ON GLASS COMPOSITION AND METHOD OF FORMING SILICON OXIDE LAYER, etc.

TRANSMITTAL

Commissioner for Patents
Washington, D.C. 20231

Sir:

Transmitted herewith is an Amendment in the above-captioned application. The fee has been calculated as shown below. *(Small entity fees indicated in parentheses.)*

CLAIMS AS AMENDED						
1	2	3	4	5	6	(7)
	Claims Remaining After Amendment		Highest Number Previously Paid For	Extra Claims	Rate	Fee
Total Claims	18		37		18.00	0.00
Small Entity					4.00	
Independent claims	5		3	2	84.00	168.00
Small Entity					42.00	
Multiple Dependent					280.00	0.00
Small Entity					140.00	
Extension of Time	One Month	Two Months	Three Months			0.00
Fee	\$110	\$400	\$920			
Small Entity	(\$55)	(\$200)	(\$460)			
Total						\$168.00

The Commissioner is hereby authorized to charge any fees associated with this filing to our Deposit Account No. 5-01645.

Respectfully submitted,
LEE & STERBA, P.C.

Date: October 8, 2002

Eugene M. Lee
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Arlington, Va. 22209



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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of :)
Jung-Ho Lee, *et al.*) Examiner: Khiem D. Nguyen
Serial No.: 09 686,624) Group Art Unit: 2823
Filed: October 12, 2000) Attorney Docket No.: 253/006

For: SPIN-ON GLASS COMPOSITION AND METHOD
OF FORMING SILICON OXIDE LAYER IN
SEMICONDUCTOR MANUFACTURING PROCESS
USING THE SAME

Assistant Commissioner for Patents
Washington, D.C. 20231

AMENDMENT AND REQUEST FOR RECONSIDERATION
PURSUANT TO 37 C.F.R. § 1.111

Sir:

In response to the Office Action mailed July 9, 2002, please amend the application
as follows:

IN THE CLAIMS:

✓ Please cancel claims 1-9, 13, and 29-37.